

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Currently Amended) An installation {2} comprising a machine {4} for the production of tablets, where the machine has at least one enclosure {6, 8, 10}, ~~characterised in that wherein~~ the installation includes means {10, 12, 16, 14} for injecting a gas into the enclosure and to distribute it throughout the enclosure, said means being arranged so as to control the temperature of the gas at a predetermined location {80} upstream of the enclosure {6} in order to ensure that the temperature of the gas in the enclosure {6} reaches a predetermined value.

2. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ said means are arranged to control the temperature of the gas at the predetermined location {80}, in order to ensure that the temperature at this location reaches a predetermined value.

3. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ said means are arranged to cool the gas.

4. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ said means are arranged to heat the gas.

5. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ said means are arranged to control the relative humidity of the gas.

6. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ said means include at least one particle filter {30, 32}.

7. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ said means include at least one fan {10, 14} placed upstream or downstream of the enclosure {6, 8, 10} for example.

8. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ the enclosure {6} includes devices {39} for shaping of the tablets.

9. (Currently Amended) An installation according to any of the preceding claims, ~~characterised in that claim 1, wherein~~ the enclosure {8} includes a motor.

10. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ the enclosure {10} includes an electronic device.

11. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ the enclosures {6, 8, 10} are at least two in number, and the machine includes means for injecting a gas into each enclosure and to distribute it.

12. (Currently Amended) An installation according to ~~the preceding claim characterised in that claim 11, wherein~~ it includes gas conduits {16} arranged to feed gas to the enclosures {6, 8, 10} using a parallel arrangement.

13. (Currently Amended) An installation according to any of claims 11 or 12, ~~characterised in that wherein~~ the means are partially common to the enclosures {6, 8, 10}.

14. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ said means include at least one gas conduit {16} connected so that it can be removed from the enclosure {6, 8, 10}.

15. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ it includes at least one stopper {36a-c, 70} to interrupt the flow of gas between the enclosure and the remainder of the installation.

16. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ said means are arranged to control a flow of gas associated with the enclosure by allowing the choice of one flow from various non-zero flow values.

17. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ said means include a diffusion box {40, 50, 62} placed in the enclosure {6, 8, 10}, having at least two openings {42} for entry of the gas into the enclosure.

18. (Currently Amended) An installation according to ~~the preceding claim characterised in that claim 17, wherein~~ the openings {42} are located on different faces of the diffusion box {40, 50, 62}.

19. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ the tablets include a substance for therapeutic or cosmetic use.

20. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein the tablets include Ibuprofen.

21. (Currently Amended) A process for the production of tablets, ~~characterised in that~~ wherein gas is injected into an enclosure {6, 8, 10} that forms part of a machine {2} for the production of tablets, and is distributed throughout the enclosure, and in that the temperature of the gas is controlled at a predetermined location {80} upstream of the enclosure in order to ensure that the temperature of the gas in the enclosure reaches a predetermined value.

22. (Currently Amended) A process according to ~~the preceding claim, characterised in that~~ claim 21, wherein the temperature of the gas is controlled at the predetermined location {80} in order to ensure that the temperature at this location reaches a predetermined value.

23. (New) A method for the production of tablets, wherein a gas is fed into an enclosure that forms part of a machine for the production of tablets, and distributed throughout the enclosure.

24. (New) A method according to claim 23, wherein the temperature of the gas is controlled.

25. (New) A method according to claim 23, wherein the temperature of the gas is controlled at a predetermined location upstream of the enclosure, in order to ensure that the temperature of the gas in the enclosure reaches a predetermined value.

26. (New) A method according to any of claims 23 to 25, wherein the temperature of the gas is controlled at a predetermined location upstream of the enclosure so that the temperature reaches a predetermined value.